

[Document Type] Abstract

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[Problem to be Solved by the Invention] To provide an exposure apparatus that can satisfactorily perform exposure and measurement processes through a liquid.

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[Means for Solving the Problem] An exposure apparatus EX has a detection apparatus 60 that detects whether a liquid is present on a substrate P or a substrate stage PST, which is disposed lower than a front end of a projection optical system PL.

10 [Selected Drawing] Fig. 1